Client Ref. M# Atty. FORM PTO-1449 (modified) Dkt. No. To: U.S. Department of Commerce (PW FORM PAT-1449) NOV 0 7 2007 Patent and Trademark Office P-1851.000-US 081468 0309196 Applicant: Aleksey Yurievich KOLESNYCHENKO, et al. INFORMATION DISCLOSURE STATEMEN BY APPLICANT Appln. No.: 10/823,777 Filing Date: April 14, 2004 Examiner: GUTIERREZ, Kevin C. Group Art Unit: 2851 of 4 Page 1 Date: November 7, 2007 U.S. PATENT DOCUMENTS Class Sub Filing Name Document Date Examiner's Date Class (Family Name of First Inventor) Number MM/YYYY Initials* (if appropriate) 7AM/ 02/2003 Suenaga AR 2003/0030916 A1 06/2004 Violette BR 2004/0118184 A1 Richter et al. 2004/0169834 A1 09/2004 CR 09/2004 Flagello et al. DR 2004/0169924 A1 Baba-Ali et al. 09/2004 ER 2004/0180294 A1 Rolland et al. 09/2004 FR 2004/0180299 A1 GR 2004/0114117 A1 06/2004 Bleeker HR 2004/0160582 A1 08/2004 Lof et al. IR 2004/0165159 A1 08/2004 Lof et al. JR 2004/0207824 A1 10/2004 Lof et al. KR 10/2004 Derksen et al. 2004/0211920 A1 LR 2004/0224265 A1 11/2004 Endo et al. MR 2004/0224525 A1 11/2004 Endo et al. NR 2004/0227923 A1 11/2004 Flagello et al. OR 2004/0253547 A1 12/2004 Endo et al. PR 2004/0253548 A1 12/2004 Endo et al. QR 2004/0257544 A1 12/2004 Vogel et al. RR 2004/0259008 A1 12/2004 Endo et al. SR 2004/0259040 A1 12/2004 Endo et al. TR 2004/0263808 A1 12/2004 Sewell UR 2006/0023182 02/2006 Novak et al. /AM/ 2006/0238730 10/2006 Nei et al. VR English Translation FOREIGN PATENT DOCUMENTS Abstract Readily Inventor Name Document Date Country Available MM/YYYY Number Enclosed No Enclose No /AM/ WR EP 0 834 773 A2 04/1998 Europe Suwa X XR JP A 57-153433 09/1982 Japan Takanashi et al. YR JP A 59-19912 02/1984 Kawamura et al. х Japan X ZR JP A 05-62877 03/1993 Japan Shinohara X AAR JP A 08-316125 11/1996 Japan Rudorufu et al. Date Considered: 01/20/2008 /Alan Mathews/ Examiner Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if **'EXAMINER:**

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